

Highly Improvement of Laser Processing for Colloidal Silicon Nanocrystal Formation in a Reactive Solvent

-Supporting Information-

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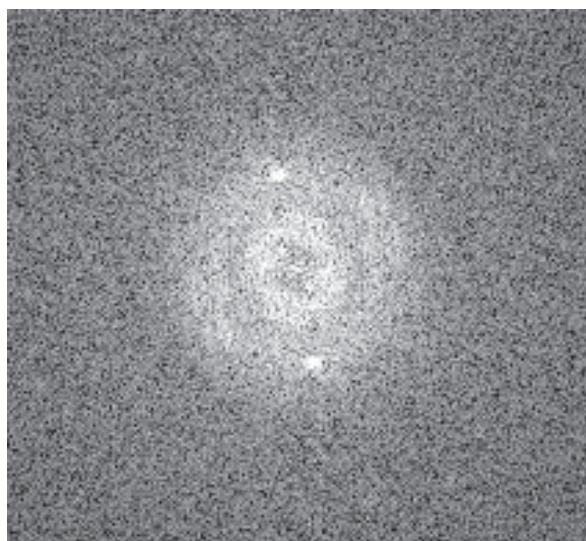


Figure S1 FFT pattern of the transmission electron microscope image in the Figure 1a.

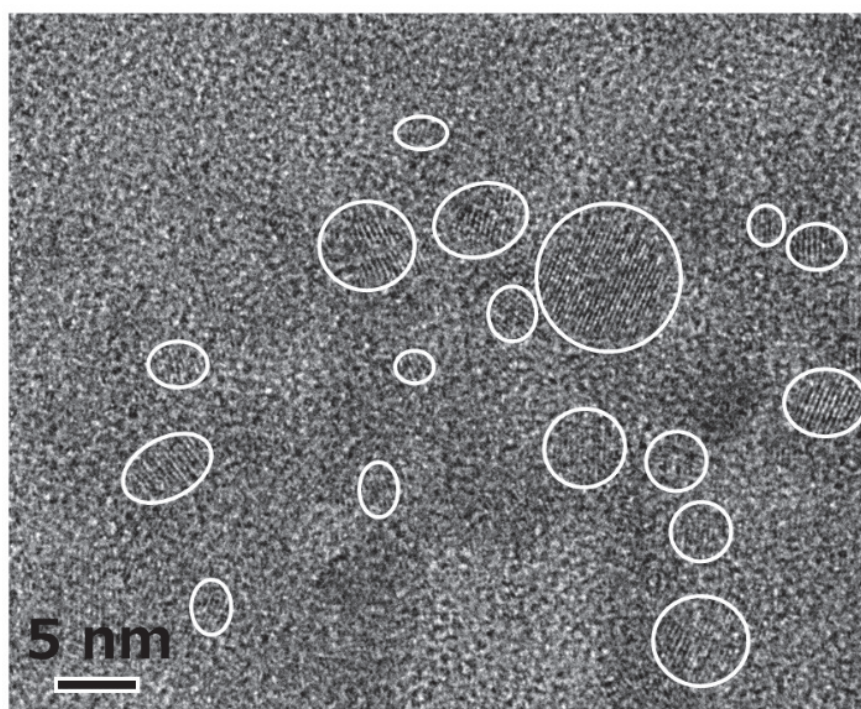


Figure S2 Transmission electron microscope image of the colloidal Si-nc sample prepared in the HF-free solvent (0 vol%).